



E-cloud Remedies and PS2 Vacuum Design

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Main Topics



- Introduction
- PS2 Vacuum Design
 - Main parameters & Vacuum implications
 - Revue of technical solutions
 - Layout & 3D Integration
- E-cloud Remedies
 - Electron cloud build up
 - Remedies validated in existing accelerators
 - On going investigations





Introduction



- The Vacuum System of the PS2 accelerator shall be designed to ensure:
 - The required beam lifetime is equivalent to PS
 - A limited effect of the beam-gas scattering
 - Dose rate induced by lost particles to the tunnel environment e.g. activation of components, damages on cables and electronics...
 - Emittance preservation
 - Dynamic Vacuum stability i.e. Ion instability
 - Beam stability
 - Low Impedance (image beam current)
 - RF shielding to avoid HOM induced heat loads and beam induced instabilities
 - Low Electron Cloud density







Main parameters & Vacuum implications

- Machine parameters
 - Beam Parameters
 - Energy: 4 Gev @ inj., 50 GeV @ extract.
 - 8×10¹¹ p/bunch, 170 bunches (~5 A)
 - 25 ns bunch spacing
 - 20 ns bunch length @ injection
 - 4 ns bunch length @ before extraction

Dynamic pressure: <10⁻⁹ mbar
Average radius: 214.3 m
Circumference: 1346.4 m
Bending radius: 99.9 m

Integrated dipole length: 627.9 m ⇒ 200 dip., L= 3 m, V=70 mm, H=250 mm

Integrated quadrupole length:174 m ⇒ 120 quad., L= 1.75 m - Pole radius 75 mm

– "Free" straight section: 545 m

Kickers & Septa (x18): 123 m

Auxiliary magnets (~170): 70 m

• Interconnecting bellows: ~150 m

Space left for other items: ~200 m

Low photon flux
High conductance on beam pipes
Critical bunch intensity for E-cloud
UHV dynamic pressure

Design of the vacuum chamber is critical if a bake out is required 5 mm for vacuum chamber thickness, bake out and alignment







Mechanical Design (1)

- Mechanical issues
 - UHV standards based on Conflat[®] flanges
 - Magnet chambers
 - Magnet chamber shall provide the maximum aperture while allowing:
 - Manufacturing tolerances: straightness 0.2 mm/m
 - Complex shape: quasi-rectangular shape
 - Space for bake out if required: 5 mm minimum on radius

 - Surface treatment/coating required for electron cloud issues ⇒ Supply the chambers to the magnet factory to avoid later problems of insertion
 - Short & Long straight sections
 - Cylindrical chambers in copper ID130 mm to stay compatible with DN150CF flanges
- Impedance
 - Copper or Aluminium chambers instead of Stainless steel with copper coating
 - Conductibility is a factor 7000 lower in copper than in stainless steel
 - ~0.8 mm copper coating required for a 70 mm height stainless steel vacuum pipe (dipole magnets)







Mechanical Design (2)

- RF Shielding
 - Expensive ⇒ reduce the number of variants
- Aperture issues
 - Smooth transition between diameters ⇒ space requirements / Costs (2.5 kCHF/unit)
 - Define a limited number standard apertures
- At the design stage, the standardisation of the vacuum components is essential since it will have an impact during the future operation of the accelerator: availability of spares!





Layout & 3D integration

- Shown to be essential in the LHC
- Absolutely required in more compact accelerators
 - Start as soon as possible
 - Set a Layout and Integration Committee
 - Define the equipment owners responsibility and the objectives for the Integration Team
 - The Layout is required to fill the Database which define the vacuum components to be manufactured
- Vacuum sectorisation
 - Vacuum requirements
 - In situ conditioning requirements
 - Exploitation requirements
 - Radiation and safety aspects
- The 3D integration aims to ensure that the vacuum system which is used to be installed while all other equipments are in place can be installed as initially foreseen i.e. avoiding compromises on pumping, bake out and vacuum instrumentations.





E-cloud Remedies



Electron Cloud built up – Review of the main parameters (1)

The Electron Cloud build up depends on:

- Beam parameters
 - Bunch intensity
 ⇒ Threshold effect: SPS case: 2-3×10¹⁰ p/bunch in dipoles 5.0×10¹⁰p/bunch in field free
 - Bunch spacing ⇒ Threshold effect: SPS case: Build up occurs for bunch spacing < 75 ns
 - Bunch pattern ⇒ Surviving electrons i.e. low energy electrons (<5 eV) are lost in missing bunches (gaps). SPS case: >225 ns required between bunch trains (batches)
 - Playing with these parameters reduces the total beam intensity...
- Surface characteristics
 - Secondary Electron Yield Characteristics

The SEY i.e. number of secondary electrons emitted by a primary electron depends on:

- Material and/or coating [talk S. Calatroni @ al. Friday a.m.]
- The surface characteristics e.g. oxide thickness, roughness, surface contamination...
- The primary electron energy
- The angle of incidence of the primary electron
- Does not depend on the existence of a strong magnetic field
- How can the SEY be reduced?
 - Appropriate choice of the material and/or coating
 - Surface treatment by glow discharge
 - Bake out
 - Geometrical effects
 - Grooves reduced the apparent SEY and the build up

 ⇒ the groove's effect could be reduced by a dipole field





E-cloud Remedies



Electron Cloud built up – Review of the main parameters (2)

The Electron Cloud build up depends on:

- Surface characteristics
 - Beam Conditioning and Vacuum Cleaning (physics aspects)
 - Beam conditioning is characterized by a decrease of the SEY resulting from the bombardment of the electrons from the cloud
 - Vacuum cleaning is characterized by the removal of the gases physisorbed and chemisorbed on the surface resulting from the bombardment of the electrons from the cloud (electron stimulated desorption).
 - The vacuum cleaning will improve the dynamic pressure (in presence of beam) but will not affect the electron cloud density which will only decrease with the beam conditioning.
 - Their rates of reduction are different
- Alternative to the reduction of the SEY
 - Clearing electrodes
 - Collect the emitted electrons before they start contributing to the build up [talk F. Caspers – Friday a.m.]
- Detrimental effect of the magnetic field
 - Field free regions ⇒ Higher build up threshold
 - Bending dipole fields enhance the electron cloud in the vertical plane ⇒ Build up threshold is reduced
 - Quadrupole fields trap the electrons along the poles ⇒ Heat load limitation for the superconducting quadrupole (not applicable in PS2)





E-cloud remedies



Remedies validated in existing accelerators

- Right choice of vacuum chamber material
 - Copper and stainless steel have a SEY as received around 2.3 to be compared with the 2.7 of aluminum
- Coating of the inner surface
 - NEG coating
 - Used as baseline for the LHC long straight sections. After activation, SEY decreases down to 1.1 and increases up to 1.3 when saturated.
 - TiN coating
 - Values measured on samples provided by RHIC and measured by N. Hilleret showed SEY values ranging from 1.5 to 1.7 after air exposure. [talk S. Calatroni @ al. – Friday a.m.]
- Glow discharge
 - Ar, Ar/O₂, N₂ glow discharge decrease the SEY but the effect is reset after a venting to air.
 - A "memory" effect is still visible and the beam conditioning is faster
- In situ bake out
 - In situ bake out reduces the SEY e.g. for copper from 2.3 down to 1.7
 - After a venting to air, the SEY is back to 2.3
- Beam conditioning
 - Beam conditioning is being successfully used in the SPS since 2002 prior to operation with LHC type beam.
 - The beam conditioning efficiency depends on the electron bombardment intensity which decreases while the SEY decreases





E-cloud remedies



On going investigations

- Low SEY coatings which:
 - Do not require an in situ bake out
 - Do not suffer from an air exposure
- In situ / ex-situ glow discharge
 - Ar/O₂ and CH4
- Clearing electrodes
- Grooves and nanostructures



Conclusions



- The PS2 Vacuum System will have:
 - The complexity of the PS accelerator in term of integration and space available for vacuum components,
 - The complexity of the LHC LSS for the impedance and HOM issues,
 - The requirements of LHC LSS for the dynamic vacuum,
 - The radiation issues comparable to the SPS extraction areas.
- Based on today's knowledge, the electron cloud suppression & vacuum requirement imply a UHV design i.e. baked vacuum system with NEG coatings to ensure vacuum stability